

Title (en)
ALLOY C11004

Title (de)
C11004 LEGIERUNG

Title (fr)
ALLIAGE C11004

Publication
EP 0866883 A4 19981223 (EN)

Application
EP 97905859 A 19970207

Priority
• US 9702030 W 19970207
• US 59961296 A 19960209

Abstract (en)
[origin: WO9729216A1] An enhanced bonding copper alloy characterized by an oxygen content generally within a range of 350 ppm to 709 ppm, an iron content generally less than about 20 ppm, a zinc content generally less than about 24 ppm, a silicon content generally less than about 31 ppm, generally less than about 31 ppm aluminum, a tin content generally less than about 10 ppm, generally less than about 10 ppm lead and about 10 ppm magnesium, a manganese content generally less than about 10 ppm, generally less than about 10 ppm cobalt, generally less than about 31 ppm nickel, and a cadmium content generally less than about 10 ppm, the balance copper.

IPC 1-7
C22C 9/00

IPC 8 full level
C22C 9/00 (2006.01)

CPC (source: EP)
C22C 9/00 (2013.01)

Citation (search report)
• [X] EP 0667640 A2 19950816 - BRUSH WELLMAN [US]
• [X] GB 2012813 A 19790801 - SUMITOMO ELECTRIC INDUSTRIES
• [PXD] US 5583317 A 19961210 - MENNUCCI JOSEPH P [US], et al
• [X] PATENT ABSTRACTS OF JAPAN vol. 012, no. 164 (M - 698) 18 May 1988 (1988-05-18)
• [X] PATENT ABSTRACTS OF JAPAN vol. 010, no. 120 (C - 343) 6 May 1986 (1986-05-06)
• [X] DATABASE WPI Section Ch Week 8637, Derwent World Patents Index; Class M23, AN 86-241414, XP002082016
• [X] DATABASE WPI Section Ch Week 8228, Derwent World Patents Index; Class L03, AN 82-58018E, XP002082017
• See references of WO 9729216A1

Designated contracting state (EPC)
AT BE CH DE DK ES FI FR GB GR IE IT LI LU MC NL PT SE

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